



4M/IWMF 2016 Conference

11th International Conference on Multi-Material Micro Manufacture (4M2016) co-organised with 10th International Workshop on Microfactories (IWMF2016)

Conference Chair: Guido Tosello, DTU, Denmark

Conference Co-Chair: Hans Nørgaard Hansen, DTU, Denmark

Kornel Ehmann, Northwestern University, USA Stefan Dimov, Birmingham University, UK



13th-15th September 2016

Kgs. Lyngby, Denmark

Organised by DTU, 4M Association, IWMF and University of Birmingham









http://www.4m-association.org/conference/2016

Scope

In today's market, miniaturised and microsystems-based products represent key value-adding elements for many industrial sectors and thus are an important contributor to a sustainable economy. Following the silicon-based microelectronics revolution of the late twentieth century, a number of micro and nano manufacturing technologies have been developed and implemented into process chains for the fabrication of Micro Electro Mechanical Systems (MEMS). Especially, these technology developments have targeted niche markets and as a consequence, a number of MEMS devices are now being effectively exploited commercially. To address the continuing trend for product miniaturisation and the constantly growing demand for novel products enabled by Micro and Nano Technologies (MNTs) the 4M Conference series has, **since 2005**, been bringing together researchers and industrialists engaged in multi-disciplinary research and development of micro and nano manufacturing platforms and their various existing and emerging application areas.



4M2016 will once again create a forum for the presentation of, and discussions about, the latest advances in manufacturing capabilities to meet the demands for:

- Product miniaturisation through innovative integration and development of knowledge-based technologies and production concepts (especially micro and nano) for the processing of non-silicon materials;
- Prediction of product and process performance to reduce/manage the risk during product development and production, and to reduce time to market for the next generation of microsystems-based products;
- Future product platforms to meet the requirements of the next generation of microsystems-based products, and of more stringent regulations and environmental legislation; and
- Production scale-up to ensure effective and efficient transfer of product and technology ideas from laboratories to serial production.

Themes

Papers are invited that present original research and development in <u>processes and process chains for multi-material micro and nano manufacture</u>, in particular but not limited to:

- Components: fabrication and assembly technologies
- Systems: novel product and system designs
- Process modelling and simulation
- Process characterisation including process chains
- Metrology: inspection and characterisation methods
- o Novel materials: characterisation and processing
- Micro and Nano Additive Manufacturing Technologies

In addition, contributions to the International Workshop on Microfactories (IWMF2016) on the following topics are invited:

Micro and Desktop Factory Concepts, Systems, Components and Modules

- Standardization in Micro Manufacturing and Micro Factories
- o High Precision Production of 3D Micro-parts
- Micro-assembly and Micro-handling

These topics represent the intended content of the 4M/IWMF 2016 thematic sessions, to which the authors are invited to submit papers. The Conference will also feature invited special sessions focussed on the latest technology and application advances achieved in major EC-funded and national programmes. The follow special session has already been agreed:

- High throughput Integrated technologies for multi-material functional MIcro Components (EU FP7 HINMICO project)
- Micro Technologies for Hearing-Aid Systems
- o Micro Manufacturing of Terahertz Technology Devices

Invited Speakers:

Ole Sigmund, Technical University of Denmark, Denmark **Placid Ferreira,** University of Illinois, USA **Helmut Schift,** Paul Scherrer Institute, Switzerland

Joint 4M/IWMF Programme Committee:

Chair: Guido Tosello, DTU, Denmark **Co-Chairs:** Hans Nørgaard Hansen, DTU, Denmark Kornel Ehmann, Northwestern University, USA Stefan Dimov, University of Birmingham, UK

Nadja Adamovich, TUWien, Austria Chantal Khan-Malek, CNRS, France Bertrand Fillon, CEA, France Massimiliano Annoni, Politecnico di Milano, Italy Hast Jukka, VTT, Finland Lionel Tenchine, IPC, France Kornel Ehmann, Northwestern University, USA Jian Cao, Northwestern University, USA Antony H.C.Lee, MIRDC, Taiwan Michael-Fu, MIRDC, Taiwan G. Maccarini, Università Degli Studi Di Bergamo, Italy Thomas Velten, Fraunhofer IBMT, Germany Susan Anson, KIT, Germany Kiwamu Ashida, AIST, Japan Dong-Woo Cho, Postech, Korea Kai Cheng, Brunel University, UK Nico de Rooij, EPFL, Switzerland Kuniaki Doda, Northwestern University, USA Fengzhou Fang, Singapore Inst. of Manuf. Tech Sergej Fatikow, University of Oldenburg, Germany Ho-chung Fu Metal Industries Research & Development Centre, Taiwan Dae-Gab Gweon, Korea Adv. Institute of Science and Tech Yong Huang, University of Florida, USA Shiv Kapoor, Univ. of Illinois at Urbana/Champaign, USA Byeong-Hee Kim, Kangwon University, Korea Jongwon Kim, Seoul National University, Korea Tae-Jo Ko, Youngnam University, Korea Liu Kui, Singapore Institute of Manufacturing Tech. Thomas R. Kurfess, Georgia Institute of Technology, USA André Zimmermann, Hahn-Schickard, Germany

Y.S. Liao, National Taiwan University Ming-Chyuan Lu, Nat. Chung Hsing Univ., Taiwan Akihiro Matsumoto, Toyo University, Japan Bernd Michel, Fraunhofer Institute, Germany Bradley Nelson, ETH Zurich Jun Ni, University of Michigan, USA Hitoshi Ohmori, Riken, Japan Yuichi Okazaki, AIST, Japan Simon Park, University of Calgary, Canada Hyung-Wook Park, UNIST, Korea Jong-Kweon Park, KIMM, Korea Duc-Truong Pham, University of Birmingham, UK Svetan Ratchev, University of Nottingham, UK Stephane Regnier, Universite Marie-Curie, France Steffen Scholz, KIT, Germany Lars Mattsson, KTH, Sweden Rhett Mayor, Georgia Institute of Technology, USA Eleonora Ferraris, KU Leuven, Belgium Martin Richter, FhG EMFT, Germany Andreas Schoth, University of Freiburg, Germany Volker Schulze, KIT, Germany Holger Reinecke, Hahn-Schickard&IMTEK, Germany Pieter Bolt, TNO, Netherlands Maurice van der Beek, Philips, Netherlands Iban Quintana, TEKNIKER, Spain Xabier Mendibil, TEKNIKER, Spain Jose Ignacio Esmoris, TEKNIKER, Spain Luis Gerardo Uriarte, TEKNIKER, Spain Elis Carlström, Swerea-IVF, Sweden Helmut Loibl, FOTEC, Austria Samuel Bigot, Cardiff University, UK Emmanuel Brousseau, Cardiff University, UK David Gardner, C-Tech Innovation, UK Seung-Kook Ro, KIMM, Korea Mitchell Tseng, Hong Kong Univ. of Sc. and Tech. Reijo Tuokko, Tampere Univ. of Tech., Finland Min-Yang Yang KAIST, Korea Quan Zhou, Aalto University, Finland

Submission of Full Papers

- Submission site opens: 1st of January 2016 Deadline: 25th March 2016
- Submission site: http://conference.4m-association.org/openconf.php

Paper Review

To ensure a high-quality Conference all papers will be reviewed by fellow authors under the leadership of the Session Chairs.

Oral and Poster presentation

Submitted papers may be selected for oral or poster presentation. All oral and poster presentations will be included in the Conference Proceedings.

Important Dates:

Submission site will open:

Submission deadline for full papers:

Feedback from the peer review to authors:

 $\circ\quad$ Submission deadline of revised final paper:

Notification of acceptance in Final Publication:

Authors Final Registration:

Public Final Registration:

1st of January 2016

25th of March 2016

16th May 2016

3rd June 2016

24th June 2016 15th July 2016

31st August 2016

Proceedings:

All final papers accepted for presentation may be included in the 4M2016 Proceedings to be published by Research Publishing Services. Selected papers may be considered for publication in Special Issues.

Conference Secretary

Afif Batal, University of Birmingham, Birmingham, UK Tel: +44 (0)121-414 4143; E-mail: a.batal@bham.ac.uk